

Day : Sunday
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Inventor Name Search Result

Your Search was:

Last Name = HASEGAWA

First Name = KOJI

Application#	Patent#	Status	Date Filed	Title	Inventor Name
<u>06704693</u>	<u>4757007</u>	150	02/22/1985	PROCESS FOR PREPARING HYDROLYZED PRODUCTS OF SOY PROTEIN	HASEGAWA, KOJI
<u>06707986</u>	Not Issued	166	03/04/1985	PROCESS FOR PREPARING CARBONATED SOFT DRINKS	HASEGAWA, KOJI
<u>07040671</u>	Not Issued	161	04/21/1987	PROCESS FOR PREPARING CARBONATED SOFT DRINKS	HASEGAWA, KOJI
<u>07974714</u>	<u>5367230</u>	150	11/12/1992	CATHODE-RAY TUBE WITH CONVERGENCE YOKE LENS SYSTEMS	HASEGAWA, KOJI
<u>08030732</u>	<u>5455345</u>	250	03/12/1993	PHYSIOLOGICALLY ACTIVE SUBSTANCES OF PLANT, PROCESS FOR THE PREPARATION THEREOF, AND UTILITIES THEREOF	HASEGAWA, KOJI
<u>08316350</u>	<u>5512673</u>	150	09/30/1994	PHYSIOLOGICALLY ACTIVE SUBSTANCES OF PLANT, PROCESS FOR THE PREPARATION THEREOF, AND UTILITIES THEREOF	HASEGAWA, KOJI
<u>08355240</u>	<u>5559563</u>	150	12/09/1994	WAVEFORM RESPONSE IMPROVEMENT CIRCUIT	HASEGAWA, KOJI
<u>08431263</u>	<u>5591697</u>	250	04/28/1995	PHYSIOLOGICALLY ACTIVE SUBSTANCES OF PLANT, PROCESS FOR THE PREPARATION THEREOF, AND UTILITIES THEREOF	HASEGAWA, KOJI
<u>08644775</u>	<u>5730901</u>	250	05/10/1996	NOVEL SILACYCLOHEXANE COMPOUNDS, PREPARATION THEREOF LIQUID CRYSTAL COMPOSITIONS COMPRISING THE SAME, AND LIQUID	HASEGAWA, KOJI

				CRYSTAL DEVICES COMPRISING THE COMPOSITION	
<u>08788778</u>	<u>5871169</u>	150	01/24/1997	PHOTOGRAPHIC FILM WITH PORTION CUT ALONG PERFORATION EDGE	HASEGAWA, KOJI
<u>09180032</u>	<u>6138695</u>	150	10/30/1998	SUBSTRATE PROCESSING APPARATUS	HASEGAWA, KOJI
<u>09307767</u>	<u>6147249</u>	150	05/10/1999	NOVEL ESTER COMPOUNDS, POLYMERS, RESIST COMPOSITION AND PATTERNING PROCESS	HASEGAWA, KOJI
<u>09404763</u>	<u>6280898</u>	150	09/24/1999	NOVEL LACTONE- CONTAINING COMPOUNDS, POLYMERS, RESIST COMPOSITIONS, AND PATTERNING METHOD	HASEGAWA, KOJI
<u>09431139</u>	<u>6312867</u>	150	11/01/1999	NOVEL ESTER COMPOUNDS, POLYMERS, RESIST COMPOSITIONS AND PATTERNING PROCESS	HASEGAWA, KOJI
<u>09512108</u>	<u>6284429</u>	150	02/24/2000	NOVEL ESTER COMPOUNDS, POLYMERS, RESIST COMPOSITIONS AND PATTERNING PROCESS	HASEGAWA, KOJI
<u>09572973</u>	<u>6413695</u>	150	05/18/2000	RESIST COMPOSITIONS AND PATTERNING PROCESS	HASEGAWA, KOJI
<u>09572975</u>	<u>6448420</u>	150	05/18/2000	ACID-DECOMPOSABLE ESTER COMPOUND SUITABLE FOR USE IN RESIST MATERIAL	HASEGAWA, KOJI
<u>09630810</u>	<u>6444396</u>	150	08/02/2000	NOVEL ESTER COMPOUNDS, POLYMERS, RESIST COMPOSITION AND PATTERNING PROCESS	HASEGAWA, KOJI
<u>09685412</u>	Not Issued	041	10/10/2000	GPS POSITIONING METHOD AND GPS RECEPTION APPARATUS	HASEGAWA, KOJI
<u>09694369</u>	<u>6667145</u>	150	10/24/2000	RESIST COMPOSITION AND PATTERNING PROCESS	HASEGAWA, KOJI
<u>09694706</u>	<u>6399274</u>	150	10/24/2000	RESIST COMPOSITION AND PATTERNING PROCESS	HASEGAWA, KOJI
<u>09704557</u>	<u>6337415</u>	150	11/03/2000	PROCESS FOR PREPARING TETRAKIS (TRIMETHYLSILY) SILANE AND TRIS (TRIMETHYLSILYL) SILANE	HASEGAWA, KOJI

<u>09711311</u>	<u>6524765</u>	150	11/14/2000	POLYMER, RESIST COMPOSITION AND PATTERNING PROCESS	HASEGAWA, KOJI
<u>09723175</u>	<u>6470726</u>	150	11/27/2000	METHOD FOR MANUFACTURING AN EXTRUDED ARTICLE CHANGING IN CROSS- SECTION AND AN APPARATUS FOR EXTRUDING SAID EXTRUDED ARTICLE	HASEGAWA, KOJI
<u>09726592</u>	<u>6492089</u>	150	12/01/2000	POLYMER, RESIST COMPOSITION AND PATTERNING PROCESS	HASEGAWA, KOJI
<u>09754320</u>	<u>6291696</u>	150	01/05/2001	PREPARATION OF TRIS (TRIMETHYLSILYL) SILYLETHYL ESTERS	HASEGAWA, KOJI
<u>09771905</u>	<u>6466163</u>	150	01/29/2001	GPS RECEIVER AND PORTABLE COMMUNICATION APPARATUS	HASEGAWA, KOJI
<u>09795939</u>	<u>6445341</u>	150	02/28/2001	GPS RECEIVER AND GPS RECEPTION METHOD	HASEGAWA, KOJI
<u>09797025</u>	<u>6480145</u>	150	03/01/2001	GPS RECEIVER AND GPS POSITION MEASUREMENT METHOD	HASEGAWA, KOJI
<u>09797878</u>	<u>6566037</u>	150	03/05/2001	POLYMER, RESIST COMPOSITION AND PATTERNING PROCESS	HASEGAWA, KOJI
<u>09797880</u>	<u>6509135</u>	150	03/05/2001	POLYMER, RESIST COMPOSITION AND PATTERNING PROCESS	HASEGAWA, KOJI
<u>09837219</u>	<u>6596463</u>	150	04/19/2001	NOVEL ESTER COMPOUNDS, POLYMERS, RESIST COMPOSITIONS AND PATTERNING PROCESS	HASEGAWA, KOJI
<u>09837378</u>	<u>6586157</u>	150	04/19/2001	NOVEL ESTER COMPOUNDS, POLYMERS, RESIST COMPOSITIONS AND PATTERNING PROCESS	HASEGAWA, KOJI
<u>09842005</u>	<u>6403822</u>	150	04/26/2001	NOVEL ESTER COMPOUNDS HAVING ALICYCLIC STRUCTURE AND METHOD FOR PREPARING SAME	HASEGAWA, KOJI
<u>09842006</u>	<u>6403823</u>	150	04/26/2001	NOVEL ESTER COMPOUNDS HAVING ALICYCLIC	HASEGAWA, KOJI

				STRUCTURE AND METHOD FOR PREPARING SAME	
<u>09842007</u>	<u>6531627</u>	150	04/26/2001	NOVEL ESTER COMPOUNDS, POLYMERS, RESIST COMPOSITIONS AND PATTERNING PROCESS	HASEGAWA, KOJI
<u>09842113</u>	<u>6492090</u>	150	04/26/2001	POLYMERS, RESIST COMPOSITIONS AND PATTERNING PROCESS	HASEGAWA, KOJI
<u>09842396</u>	<u>6566038</u>	150	04/26/2001	POLYMERS, RESIST COMPOSITIONS AND PATTERNING PROCESS	HASEGAWA, KOJI
<u>09867656</u>	<u>6500961</u>	150	05/31/2001	NOVEL LACTONE COMPOUNDS HAVING ALICYCLIC STRUCTURE AND THEIR MANUFACTURING METHOD	HASEGAWA, KOJI
<u>09873193</u>	<u>6500971</u>	150	06/05/2001	NOVEL ESTER COMPOUNDS HAVING ALICYCLIC AND OXIRANE STRUCTURES AND METHOD FOR PREPARING THE SAME	HASEGAWA, KOJI
<u>09897985</u>	<u>6472543</u>	150	07/05/2001	NOVEL LACTONE COMPOUNDS HAVING ALICYCLIC STRUCTURE AND THEIR MANUFACTURING METHOD	HASEGAWA, KOJI
<u>09922635</u>	<u>6515149</u>	150	08/07/2001	ACETAL COMPOUND, POLYMER, RESIST COMPOSITION AND PATTERNING RESPONSE	HASEGAWA, KOJI
<u>09951523</u>	<u>6673515</u>	150	09/14/2001	POLYMER, RESIST COMPOSITION AND PATTERNING PROCESS	HASEGAWA, KOJI
<u>09963465</u>	<u>6780563</u>	150	09/27/2001	POLYMER, RESIST COMPOSITION AND PATTERNING PROCESS	HASEGAWA, KOJI
<u>09967946</u>	<u>6515150</u>	150	10/02/2001	CYCLIC ACETAL COMPOUND, POLYMER, RESIST COMPOSITION AND PATTERNING PROCESS	HASEGAWA, KOJI
<u>09986274</u>	<u>6660448</u>	150	11/08/2001	POLYMER, RESIST COMPOSITION AND PATTERNING PROCESS	HASEGAWA, KOJI
<u>10012419</u>	<u>6774258</u>	150	12/12/2001	NOVEL TERTIARY ALCOHOL COMPOUNDS HAVING	HASEGAWA, KOJI

				ALICYCLIC STRUCTURE	
10025064	6469220	150	12/19/2001	NOVEL TERTIARY ALCOHOL COMPOUNDS HAVING AN ALICYCLIC STRUCTURE	HASEGAWA, KOJI
10050478	6677101	150	01/16/2002	POLYMERS, RESIST MATERIALS, AND PATTERN FORMATION METHOD	HASEGAWA, KOJI
10058833	6589911	150	01/30/2002	WEEDING METHOD WITH SODIUM HYDROGEN CARBONATE	HASEGAWA, KOJI

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Inventor Name Search Result

Your Search was:

Last Name = KINSHO

First Name = TAKESHI

Application#	Patent#	Status	Date Filed	Title	Inventor Name
<u>08262542</u>	Not Issued	161	06/20/1994	SILACYCLOHEXANE COMPOUND, A METHOD OF PREPARING IT AND A LIQUID CRYSTAL COMPOSITION CONTAINING IT	KINSHO, TAKESHI
<u>08267027</u>	5454977	250	06/21/1994	SILACYCLOHEXANE COMPOUND, A METHOD OF PREPARING IT AND A LIQUID CRYSTAL COMPOSITION CONTAINING IT	KINSHO, TAKESHI
<u>08322549</u>	5547606	150	10/13/1994	SILACYCLOHEXANE COMPOUND, A METHOD OF PREPARING IT AND A LIQUID CRYSTAL COMPOSITION CONTAINING IT	KINSHO, TAKESHI
<u>08331957</u>	5659059	150	10/31/1994	SILACYCLOHEXANE COMPOUND, A METHOD OF PREPARING IT AND A LIQUID CRYSTAL COMPOSITION CONTAINING IT	KINSHO, TAKESHI
<u>08341218</u>	5496501	150	12/05/1994	SILACYCLOHEXANE COMPOUND, A METHOD OF PREPARING IT AND A LIQUID CRYSTAL COMPOSITION CONTAINING IT	KINSHO, TAKESHI
<u>08362964</u>	5573705	250	12/23/1994	SILACYCLOHEXANE COMPOUND, A METHOD OF PREPARING IT AND A LIQUID CRYSTAL COMPOSITION CONTAINING IT	KINSHO, TAKESHI
<u>08377961</u>	5498737	150	01/25/1995	SILACYCLOHEXANE COMPOUND, A METHOD OF PREPARING IT AND A LIQUID CRYSTAL COMPOSITION	KINSHO, TAKESHI

				CONTAINING IT	
<u>08383368</u>	5567350	250	02/03/1995	SILACYCLOHEXANE COMPOUND, A METHOD OF PREPARING IT AND A LIQUID CRYSTAL COMPOSITION CONTAINING IT	KINSHO, TAKESHI
<u>08388307</u>	5523440	150	02/14/1995	SILACYCLOHEXANE COMPOUND, A METHOD OF PREPARING IT AND A LIQUID CRYSTAL COMPOSITION CONTAINING IT	KINSHO, TAKESHI
<u>08388308</u>	5543539	150	02/14/1995	SILACYCLOHEXANE COMPOUND, A METHOD OF PREPARING IT AND A LIQUID CRYSTAL COMPOSITION CONTAINING IT	KINSHO, TAKESHI
<u>08395706</u>	5582764	250	02/28/1995	SILACYCLOHEXANE COMPOUND, A METHOD OF PREPARING IT AND A LIQUID CRYSTAL COMPOSITION CONTAINING IT	KINSHO, TAKESHI
<u>08408961</u>	5641431	150	03/23/1995	SILACYCLOHEXANONE COMPOUND AND A METHOD OF PREPARING A SILACYCLOHEXANE-TYPE LIQUID CRYSTAL COMPOSITION CONTAINING IT	KINSHO, TAKESHI
<u>08415858</u>	5578244	250	04/03/1995	SILACYCLOHEXANE COMPOUND, A METHOD OF PREPARING IT AND A LIQUID CRYSTAL COMPOSITION CONTAINING IT	KINSHO, TAKESHI
<u>08434814</u>	5527490	150	05/04/1995	SILACYCLOHEXANE CARBALDEHYDE COMPOUNDS AND PROCESSES FOR PREPARING SILACYCLOHEXANE-BASED LIQUID CRYSTAL COMPOUNDS FROM THE CARBALDEHYDE COMPOUND	KINSHO, TAKESHI
<u>08483034</u>	5693841	150	06/07/1995	CYCLOHEXANONE COMPOUNDS, PROCESS FOR PREPARING THE SAME, AND PROCESSES FOR PREPARING SILACYCLOHEXANE-BASED LIQUID CRYSTAL	KINSHO, TAKESHI

				COMPOUNDS FROM THE CYCLOHEXANONE COMPOUNDS	
<u>08491141</u>	5560866	250	06/16/1995	PROCESS FOR PREPARING SILACYCLOHEXANE COMPOUNDS	KINSHO, TAKESHI
<u>08501522</u>	5514824	150	07/12/1995	PROCESS FOR PREPARING SILACYCLOHEXANE-BASE LIQUID CRYSTAL COMPOUNDS	KINSHO, TAKESHI
<u>08501524</u>	5519156	150	07/12/1995	CYCLOHEXANE CARBALDEHYDE COMPOUNDS AND PROCESSES FOR PREPARING SILACYCLOHEXANE-BASED LIQUID CRYSTAL COMPOUNDS FROM THE CARBALDEHYDE COMPOUND	KINSHO, TAKESHI
<u>08511276</u>	5582765	250	08/04/1995	TRIFLATE COMPOUNDS AND PROCESS FOR PREPARING SILACYCLOHEXANE-BASED LIQUID CRYSTAL COMPOUNDS FROM THE TRIFLATE COMPOUNDS	KINSHO, TAKESHI
<u>08511816</u>	5523439	150	08/07/1995	PROCESS FOR PREPARING SILACYCLOHEXANE COMPOUNDS	KINSHO, TAKESHI
<u>08514085</u>	5868961	250	08/11/1995	SILACYCLOHEXANE COMPOUND, A METHOD OF PREPARING IT AND A LIQUID CRYSTAL COMPOSITION CONTAINING IT	KINSHO, TAKESHI
<u>08523095</u>	5595686	250	09/01/1995	NOVEL SILACYCLOHEXANE COMPOUNDS, A LIQUID CRYSTAL COMPOSITION COMPRISING THE SAME AND A LIQUID CRYSTAL DEVICE COMPRISING THE COMPOSITION	KINSHO, TAKESHI
<u>08545889</u>	5650092	150	10/20/1995	NOVEL SILACYCLOHEXANE COMPOUNDS, A LIQUID CRYSTAL COMPOSITION COMPRISING THE SAME AND A LIQUID CRYSTAL DEVICE COMPRISING THE COMPOSITION	KINSHO, TAKESHI
<u>08546254</u>	5624601	150	10/20/1995	NOVEL SILACYCLOHEXANE	KINSHO,

				COMPOUNDS, A LIQUID CRYSTAL COMPOSITION COMPRISING THE SAME AND A LIQUID CRYSTAL DEVICE COMPRISING THE COMPOSITION	TAKESHI
<u>08566392</u>	<u>5641430</u>	<u>150</u>	12/01/1995	NOVEL SILACYCLOHEXANE COMPOUNDS, PREPARATION THEREOF, LIQUID CRYSTAL COMPOSITIONS COMPRISING THE SAME, AND LIQUID CRYSTAL DEVICES COMPRISING THE COMPOSITIONS	KINSHO, TAKESHI
<u>08576319</u>	<u>5762826</u>	<u>250</u>	12/21/1995	LIQUID CRYSTAL COMPOSITION AND A LIQUID CRYSTAL DISPLAY ELEMENT WHICH CONTAINS IT	KINSHO, TAKESHI
<u>08576619</u>	<u>5679746</u>	<u>150</u>	12/21/1995	SILACYCLOHEXANE COMPOUND, A METHOD OF PREPARING IT AND A LIQUID CRYSTAL COMPOSITION CONTAINING IT	KINSHO, TAKESHI
<u>08598595</u>	<u>5665271</u>	<u>150</u>	02/12/1996	NOVEL SILACYCLOHEXANE COMPOUNDS, PREPARATION THEREOF, LIQUID CRYSTAL COMPOSITIONS COMPRISING THE SAME, AND LIQUID CRYSTAL DEVICES COMPRISING THE COMPOSITIONS	KINSHO, TAKESHI
<u>08616384</u>	<u>6004478</u>	<u>250</u>	03/15/1996	NOVEL SILACYCLOHEXANE COMPOUNDS, PREPARATION THEREOF, LIQUID CRYSTAL COMPOSITIONS COMPRISING THE SAME, AND LIQUID CRYSTAL DEVICES COMPRISING THE COMPOSITION	KINSHO, TAKESHI
<u>08828707</u>	<u>5866037</u>	<u>150</u>	03/31/1997	LIQUID CRYSTAL COMPOSITIONS AND LIQUID CRYSTAL DISPLAY ELEMENTS CONTAINING SAME	KINSHO, TAKESHI
<u>09307767</u>	<u>6147249</u>	<u>150</u>	05/10/1999	NOVEL ESTER COMPOUNDS, POLYMERS, RESIST COMPOSITION AND PATTERNING PROCESS	KINSHO, TAKESHI

<u>09404763</u>	6280898	150	09/24/1999	NOVEL LACTONE-CONTAINING COMPOUNDS, POLYMERS, RESIST COMPOSITIONS, AND PATTERNING METHOD	KINSHO, TAKESHI
<u>09431139</u>	6312867	150	11/01/1999	NOVEL ESTER COMPOUNDS, POLYMERS, RESIST COMPOSITIONS AND PATTERNING PROCESS	KINSHO, TAKESHI
<u>09512108</u>	6284429	150	02/24/2000	NOVEL ESTER COMPOUNDS, POLYMERS, RESIST COMPOSITIONS AND PATTERNING PROCESS	KINSHO, TAKESHI
<u>09572973</u>	6413695	150	05/18/2000	RESIST COMPOSITIONS AND PATTERNING PROCESS	KINSHO, TAKESHI
<u>09572975</u>	6448420	150	05/18/2000	ACID-DECOMPOSABLE ESTER COMPOUND SUITABLE FOR USE IN RESIST MATERIAL	KINSHO, TAKESHI
<u>09630810</u>	6444396	150	08/02/2000	NOVEL ESTER COMPOUNDS, POLYMERS, RESIST COMPOSITION AND PATTERNING PROCESS	KINSHO, TAKESHI
<u>09694369</u>	6667145	150	10/24/2000	RESIST COMPOSITION AND PATTERNING PROCESS	KINSHO, TAKESHI
<u>09694706</u>	6399274	150	10/24/2000	RESIST COMPOSITION AND PATTERNING PROCESS	KINSHO, TAKESHI
<u>09704557</u>	6337415	150	11/03/2000	PROCESS FOR PREPARING TETRAKIS (TRIMETHYLSILYL) SILANE AND TRIS (TRIMETHYLSILYL) SILANE	KINSHO, TAKESHI
<u>09711311</u>	6524765	150	11/14/2000	POLYMER, RESIST COMPOSITION AND PATTERNING PROCESS	KINSHO, TAKESHI
<u>09726592</u>	6492089	150	12/01/2000	POLYMER, RESIST COMPOSITION AND PATTERNING PROCESS	KINSHO, TAKESHI
<u>09754320</u>	6291696	150	01/05/2001	PREPARATION OF TRIS (TRIMETHYLSILYL) SILETHYL ESTERS	KINSHO, TAKESHI
<u>09760716</u>	6653044	150	01/17/2001	CHEMICAL AMPLIFICATION TYPE RESIST COMPOSITION	KINSHO, TAKESHI
<u>09797878</u>	6566037	150	03/05/2001	POLYMER, RESIST COMPOSITION AND PATTERNING PROCESS	KINSHO, TAKESHI
<u>09797880</u>	6509135	150	03/05/2001	POLYMER, RESIST	KINSHO,

				COMPOSITION AND PATTERNING PROCESS	TAKESHI
09832919	6605408	150	04/12/2001	RESIST COMPOSITION AND PATTERNING PROCESS	KINSHO, TAKESHI
09837219	6596463	150	04/19/2001	NOVEL ESTER COMPOUNDS, POLYMERS, RESIST COMPOSITIONS AND PATTERNING PROCESS	KINSHO, TAKESHI
09837378	6586187	150	04/19/2001	NOVEL ESTER COMPOUNDS, POLYMERS, RESIST COMPOSITIONS AND PATTERNING PROCESS	KINSHO, TAKESHI
09842005	6403822	150	04/26/2001	NOVEL ESTER COMPOUNDS HAVING ALICYCLIC STRUCTURE AND METHOD FOR PREPARING SAME	KINSHO, TAKESHI

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Inventor Name Search Result

Your Search was:

Last Name = WATANABE

First Name = TAKERU

Application#	Patent#	Status	Date Filed	Title	Inventor Name
<u>09307767</u>	6147249	150	05/10/1999	NOVEL ESTER COMPOUNDS, POLYMERS, RESIST COMPOSITION AND PATTERNING PROCESS	WATANABE, TAKERU
<u>09431139</u>	6312867	150	11/01/1999	NOVEL ESTER COMPOUNDS, POLYMERS, RESIST COMPOSITIONS AND PATTERNING PROCESS	WATANABE, TAKERU
<u>09512108</u>	6284429	150	02/24/2000	NOVEL ESTER COMPOUNDS, POLYMERS, RESIST COMPOSITIONS AND PATTERNING PROCESS	WATANABE, TAKERU
<u>09572973</u>	6413695	150	05/18/2000	RESIST COMPOSITIONS AND PATTERNING PROCESS	WATANABE, TAKERU
<u>09572975</u>	6448420	150	05/18/2000	ACID-DECOMPOSABLE ESTER COMPOUND SUITABLE FOR USE IN RESIST MATERIAL	WATANABE, TAKERU
<u>09630810</u>	6444396	150	08/02/2000	NOVEL ESTER COMPOUNDS, POLYMERS, RESIST COMPOSITION AND PATTERNING PROCESS	WATANABE, TAKERU
<u>09694369</u>	6667145	150	10/24/2000	RESIST COMPOSITION AND PATTERNING PROCESS	WATANABE, TAKERU
<u>09694706</u>	6399274	150	10/24/2000	RESIST COMPOSITION AND PATTERNING PROCESS	WATANABE, TAKERU
<u>09697921</u>	6673511	150	10/27/2000	RESIST COMPOSITION	WATANABE, TAKERU
<u>09704557</u>	6337415	150	11/03/2000	PROCESS FOR PREPARING TETRAKIS (TRIMETHYLSILY) SILANE AND TRIS (TRIMETHYLSILYL) SILANE	WATANABE, TAKERU
<u>09711311</u>	6524765	150	11/14/2000	POLYMER, RESIST	WATANABE,

				COMPOSITION AND PATTERNING PROCESS	TAKERU
<u>09754320</u>	6291696	150	01/05/2001	PREPARATION OF TRIS (TRIMETHYLSILYL) SILETHYL ESTERS	WATANABE, TAKERU
<u>09797878</u>	6566037	150	03/05/2001	POLYMER, RESIST COMPOSITION AND PATTERNING PROCESS	WATANABE, TAKERU
<u>09797880</u>	6509135	150	03/05/2001	POLYMER, RESIST COMPOSITION AND PATTERNING PROCESS	WATANABE, TAKERU
<u>09837219</u>	6596462	150	04/19/2001	NOVEL ESTER COMPOUNDS, POLYMERS, RESIST COMPOSITIONS AND PATTERNING PROCESS	WATANABE, TAKERU
<u>09837378</u>	6586157	150	04/19/2001	NOVEL ESTER COMPOUNDS, POLYMERS, RESIST COMPOSITIONS AND PATTERNING PROCESS	WATANABE, TAKERU
<u>09842005</u>	6403822	150	04/26/2001	NOVEL ESTER COMPOUNDS HAVING ALICYCLIC STRUCTURE AND METHOD FOR PREPARING SAME	WATANABE, TAKERU
<u>09842006</u>	6403823	150	04/26/2001	NOVEL ESTER COMPOUNDS HAVING ALICYCLIC STRUCTURE AND METHOD FOR PREPARING SAME	WATANABE, TAKERU
<u>09842007</u>	6531627	150	04/26/2001	NOVEL ESTER COMPOUNDS, POLYMERS, RESIST COMPOSITIONS AND PATTERNING PROCESS	WATANABE, TAKERU
<u>09842113</u>	6492090	150	04/26/2001	POLYMERS, RESIST COMPOSITIONS AND PATTERNING PROCESS	WATANABE, TAKERU
<u>09842396</u>	6566038	150	04/26/2001	POLYMERS, RESIST COMPOSITIONS AND PATTERNING PROCESS	WATANABE, TAKERU
<u>09867656</u>	6500961	150	05/31/2001	NOVEL LACTONE COMPOUNDS HAVING ALICYCLIC STRUCTURE AND THEIR MANUFACTURING METHOD	WATANABE, TAKERU
<u>09873193</u>	6500971	150	06/05/2001	NOVEL ESTER COMPOUNDS HAVING ALICYCLIC AND OXIRANE STRUCTURES AND METHOD FOR PREPARING	WATANABE, TAKERU

				THE SAME	
<u>09897985</u>	6472843	150	07/05/2001	NOVEL LACTONE COMPOUNDS HAVING ALICYCLIC STRUCTURE AND THEIR MANUFACTURING METHOD	WATANABE, TAKERU
<u>09922635</u>	6515149	150	08/07/2001	ACETAL COMPOUND, POLYMER, RESIST COMPOSITION AND PATTERNING RESPONSE	WATANABE, TAKERU
<u>09951523</u>	6673515	150	09/14/2001	POLYMER, RESIST COMPOSITION AND PATTERNING PROCESS	WATANABE, TAKERU
<u>09963465</u>	6780563	150	09/27/2001	POLYMER, RESIST COMPOSITION AND PATTERNING PROCESS	WATANABE, TAKERU
<u>09967946</u>	6515150	150	10/02/2001	CYCLIC ACETAL COMPOUND, POLYMER, RESIST COMPOSITION AND PATTERNING PROCESS	WATANABE, TAKERU
<u>09986274</u>	6660448	150	11/08/2001	POLYMER, RESIST COMPOSITION AND PATTERNING PROCESS	WATANABE, TAKERU
<u>09994808</u>	6749988	150	11/28/2001	AMINE COMPOUNDS, RESIST COMPOSITIONS AND PATTERNING PROCESS	WATANABE, TAKERU
<u>10003288</u>	6743564	150	12/06/2001	AMINE COMPOUNDS, RESIST COMPOSITIONS AND PATTERNING PROCESS	WATANABE, TAKERU
<u>10012419</u>	6774258	150	12/12/2001	NOVEL TERTIARY ALCOHOL COMPOUNDS HAVING ALICYCLIC STRUCTURE	WATANABE, TAKERU
<u>10025064</u>	6469220	150	12/19/2001	NOVEL TERTIARY ALCOHOL COMPOUNDS HAVING AN ALICYCLIC STRUCTURE	WATANABE, TAKERU
<u>10106459</u>	6517994	150	03/27/2002	LACTONE RING-CONTAINING (METH) ACRYLATE AND POLYMER THEREOF FOR PHOTORESIST COMPOSITION	WATANABE, TAKERU
<u>10117218</u>	6509481	150	04/08/2002	NOVEL TETRAHYDROFURAN COMPOUNDS HAVING ALICYCLIC STRUCTURE	WATANABE, TAKERU
<u>10126877</u>	6794111	150	04/22/2002	POLYMERS, RESIST COMPOSITIONS AND PATTERNING PROCESS,	WATANABE, TAKERU

				NOVEL TETRAHYDROFURAN COMPOUNDS AND THEIR PREPARATION	
10127120	Not Issued	041	04/22/2002	NOVEL TERTIARY AMINE COMPOUNDS HAVING AN ESTER STRUCTURE AND PROCESSES FOR PREPARING SAME	WATANABE, TAKERU
10167393	Not Issued	094	06/13/2002	NOVEL EPOXY COMPOUND HAVING ALICYCLIC STRUCTURE, POLYMER, RESIST COMPOSITION AND PATTERNING PROCESS	WATANABE, TAKERU
10167444	6746818	150	06/13/2002	NOVEL (METH) ACRYLATES HAVING LACTONE STRUCTURE, POLYMERS, PHOTORESIST COMPOSITIONS AND PATTERNING PROCESS	WATANABE, TAKERU
10189706	Not Issued	041	07/03/2002	NOVEL EPOXY COMPOUNDS HAVING AN ALICYCLIC STRUCTURE, POLYMER COMPOUNDS, RESIST MATERIALS, AND PATTERNING METHODS	WATANABE, TAKERU
10219139	6743566	150	08/16/2002	CYCLIC ACETAL COMPOUND, POLYMER, RESIST COMPOSITION AND PATTERNING PROCESS	WATANABE, TAKERU
10288514	6670498	150	11/06/2002	NOVEL ESTER COMPOUNDS, POLYMERS, RESIST COMPOSITIONS AND PATTERNING PROCESS	WATANABE, TAKERU
10315069	Not Issued	094	12/10/2002	ACETAL COMPOUND, POLYMER, RESIST COMPOSITION AND PATTERNING RESPONSE	WATANABE, TAKERU
10390795	Not Issued	161	03/19/2003	NOVEL ESTER COMPOUNDS POLYMERS, RESIST COMPOSITIONS AND PATTERNING PROCESS	WATANABE, TAKERU
10615683	Not Issued	092	07/09/2003	RESIST COMPOSITION	WATANABE, TAKERU
10671732	Not Issued	041	09/29/2003	POLYMERIZABLE SILICON-CONTAINING COMPOUND, MANUFACTURING METHOD, POLYMER, RESIST	WATANABE, TAKERU

				COMPOSITION AND PATTERNING PROCESS	
10671791	Not Issued	019	09/29/2003	NOVEL TERTIARY (METH) ACRYLATES HAVING LACTONE STRUCTURE, POLYMERS, RESIST COMPOSITIONS AND PATTERNING PROCESS	WATANABE, TAKERU
10671948	Not Issued	071	09/29/2003	NOVEL ESTER COMPOUNDS, POLYMERS, RESIST COMPOSITIONS AND PATTERNING PROCESS	WATANABE, TAKERU
10791843	Not Issued	041	03/04/2004	ALICYCLIC METHACRYLATE HAVING OXYGEN SUBSTITUENT GROUP ON ALPHA-METHYL	WATANABE, TAKERU
10849186	Not Issued	030	05/20/2004	BASIC COMPOUND, RESIST COMPOSITION AND PATTERNING PROCESS	WATANABE, TAKERU

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